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Design of a new process for the stabilization of FeS–Bi₂S₃ hybrid nanostructure and its application as a field emitter†

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The relentless pursuit for technological advancement has fuelled intensive research into nanoarchitectures as fundamental components of various devices. One-dimensional (1-D) nanomaterials, including nanorods, nanowires, and nanotubes, have garnered significant attention due to their distinctive catalytic, optical, and electronic properties. Metal chalcogenides have emerged as promising candidates for diverse applications ranging from sensing devices to solar cells, particularly bismuth sulphide (Bi₂S₃). Bi₂S₃ exhibits unique properties owing to its low work function and anisotropic crystal structure. This work presents a novel approach to synthesize Bi₂S₃ nanorods and decorate them with FeS to form an FeS–Bi₂S₃ heterostructure via a one-step, template-free hydrothermal method. The synthesized nanomaterials are evaluated for their field emission characteristics, which are vital properties for numerous electronic applications. By comparing the field emission behaviour of the pristine Bi₂S₃ and FeS–Bi₂S₃ heterostructures, insights into the impact of hetero-structuring FeS for field emission performances are elucidated. This study presents insights into tailoring the heterostructure of different transition metals with Bi₂S₃ and studying their field emission behaviours.

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1. Introduction

With growing technological advancement, the research into well-defined nanoarchitectures as building block for devices have gained significant interest. One dimensional (1-D) nanomaterials, like nanorods, nanowires as well as nanotubes, have extensively been used due to their distinguished catalytic, optical, and electronic properties.¹ Various efforts have been made to tailor the structures and geometries of various nanomaterials via physical and chemical methods in a controlled manner.^{2,3} Amongst the plethora of materials, metal chalcogenides have attracted tremendous interest due to their various fascinating properties and extensive applications in sensing devices, photocatalysis, batteries, solar cells, and field emission.^{4–6} Literature on MoS₂, ZnO, MoO₃, LaS and MnS show that they can be promising alternatives to conventional carbon nanotube-based field emitters for better field emission performances.^{7–11} Bismuth sulphide (Bi₂S₃) belongs to the metal chalcogenide family of the A₂B₃ type, where A may be

As, Sb or Bi and B may be S, Se and Te. Bi₂S₃ crystallizes in an orthorhombic lattice and *Pnma* space group.¹² It has a low work function of 4.93 eV that makes it favourable for extensive usage in light emitting diodes, IR detection systems, photoconductive devices, and field emission.^{13,14} The reason for the anisotropic nature of this chemical compound is due its structural formation of Bi³⁺ and S^{2–} that are aligned on top of each other, forming an infinite number of chains, mainly along the [001] axis in its orthorhombic lattice. Bi₂S₃ is mainly an n-type semiconductor containing sulphur vacancies, which makes the tuning of its conductivity easy.¹⁵ Among the various morphologies obtained, such as stars, ribbons, rods, belts, and snow-flakes, using different synthetic methods of Bi₂S₃, rods are the one that are associated with the quantum confinement of charge.¹⁵ Various chemical methods have been reported for the synthesis of Bi₂S₃, such as hydrothermal synthesis, solvothermal synthesis, sol-gel method, chemical vapour deposition, spray pyrolysis, microwave assisted method, and atomic layer deposition.^{16–18} The hydrothermal method has been proven to be advantageous over the others because of the feasibility to control the crystallinity and morphology of the product by altering various reaction parameters, such as pH, reaction time, and temperature. Also, it is an economical and energy-efficient process. In the study by Ge *et al.*¹⁹ Bi₂S₃ nanotubes, nanowires and nanorods were synthesized via the solvothermal method at 200 °C using Na₂S as the sulphur source, urea as the pH modifier and ethanediol as the solvent.

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Subsequently, the as-formed Bi_2S_3 was sintered at 673 K and its bulk properties were studied. Wang *et al.*²⁰ synthesized ultrafine nanowires of Bi_2S_3 with a diameter of 35 nm *via* the CVD technique, which were used in near infrared photo-detectors. In the study by Yu *et al.* $\text{Bi}(\text{NO}_3)_3$ was first precipitated by tetramethylammonium hydroxide, and then the precursors together with Na_2S were kept in a Teflon-lined stainless steel hydrothermal bomb at 180 °C for 3 days. The as-synthesized Bi_2S_3 nanowires were used for field emission studies with an initial field of $26 \text{ V } \mu\text{m}^{-1}$ (@10 $\mu\text{A cm}^{-2}$) and field enhancement factor of 200.¹² In another work by Yu *et al.*²¹ Bi_2S_3 nanoflowers were synthesized *via* the chemical vapour deposition process. The ultrathin petals of the formed nanoflowers showed a turn on field of $7.45 \text{ V } \mu\text{m}^{-1}$ (@10 $\mu\text{A cm}^{-2}$) and field enhancement factor of 1.23×10^3 . Ganesh *et al.*²² synthesized upright nanoplatelets of Bi_2S_3 on an ITO-glass substrate. However, the as-synthesized Bi_2S_3 nanoplates were unable to withstand an electric field above $3.5 \text{ V } \mu\text{m}^{-1}$ and were degenerated above a current density of $49 \text{ } \mu\text{A cm}^{-2}$ despite showing a low turn-on field of $2.83 \text{ V } \mu\text{m}^{-1}$ (@10 $\mu\text{A cm}^{-2}$) and field enhancement factor of 9393.

Besides morphology optimisation for better field emission parameters, tuning the electronic structure of materials has also been proven to alter the characteristic properties of field emission. Over the years, various well-defined nanoarchitectures have attracted attention because of their potential use in various nanodevices. Zhang *et al.*²³ reported a turn-on electric field of $6.4 \text{ V } \mu\text{m}^{-1}$ and a field enhancement factor of 1158 using graphene supported on ZnO nanorod arrays. In the work by Sreekanth *et al.*^{24,25} carbon nanotubes (CNT) decorated with In and Cu were proven to produce large variations in emission current density. The introduction of the metal into the lattice of the CNTs played a crucial role in altering their field emission properties. Similarly, in the work by Shubham *et al.*²⁶ both Cu and In were decorated on CNTs and their effect on the field emission properties of the CNTs were observed. They observed that for the chosen metals, *i.e.* Cu and In, only monometallic decoration on CNTs enhanced their field emission characteristics, whereas they decreased upon bi-metallic decoration.

In the present work, nanorods of Bi_2S_3 were synthesized and FeS was introduced to form a $\text{FeS-Bi}_2\text{S}_3$ heterostructure in a simple one-step, template-free hydrothermal approach. Also, the field emission behaviour of the as-synthesized Bi_2S_3 and $\text{FeS-Bi}_2\text{S}_3$ was further compared.

2. Experimental

2.1. Materials

Bismuth(III) nitrate pentahydrate (CDH Chemicals, $\geq 98.5\%$, $\text{Bi}(\text{NO}_3)_3 \cdot 5\text{H}_2\text{O}$), thioacetamide (TAA) (CDH Chemicals, 99%, $\text{C}_2\text{H}_5\text{NS}$), iron(II) nitrate nonahydrate (Merck, $\geq 99.5\%$, $\text{Fe}(\text{NO}_3)_2 \cdot 6\text{H}_2\text{O}$). All chemicals were utilized without any further purification. Deionised water (DI) was used to carry out the reactions.

2.2. Synthesis of Bi_2S_3 and $\text{Fe-Bi}_2\text{S}_3$

In 20 mL DI water, 0.04 M of $\text{Bi}(\text{NO}_3)_3 \cdot 5\text{H}_2\text{O}$ was dispersed. Separately, 0.2 M TAA was dissolved in the same amount of DI water. The solution of TAA was slowly added to the $\text{Bi}(\text{NO}_3)_3 \cdot 5\text{H}_2\text{O}$ dispersed in water. Then, the above-mentioned solution was stirred for 30 min and placed in a 50 mL Teflon-lined stainless steel autoclave for 24 h at 200 °C. After the hydrothermal reaction, the autoclave was cooled to room temperature naturally. The resultant black product obtained was repeatedly washed with DI water and absolute ethanol, and finally dried in a vacuum oven at 60 °C for 12 h.

Similarly, $\text{FeS-Bi}_2\text{S}_3$ was prepared using the same method except that 0.01 M of $\text{Fe}(\text{NO}_3)_2 \cdot 6\text{H}_2\text{O}$ was added together with $\text{Bi}(\text{NO}_3)_3 \cdot 5\text{H}_2\text{O}$ and kept in a hydrothermal bomb for 24 h at 200 °C. The black product obtained was readily rinsed with DI water and absolute ethanol and dried at 60 °C in a vacuum oven for 12 h.

2.3. Characterization

The powder X-ray diffraction (PXRD) studies were performed using a Bruker D8 Advance X-ray diffractometer with Ni-filtered $\text{Cu-K}\alpha$ radiation having a wavelength $1.5406 \text{ \AA}$ at an increment of 0.008° and step time of 1 s. Transmission electron microscopy (TEM) was carried out using a JEOL JEM2100 instrument at a voltage 200 of kV. For the TEM analysis, the samples were properly dispersed in absolute ethanol by ultrasonication and drop-casted over carbon-coated Cu grids (200 mesh). A WITTEC Raman spectrometer was used to carry out the Raman analysis using a 532 nm laser. The oxidation state of the elements and work function were analysed by X-ray photoelectron spectroscopy (XPS) and ultraviolet photoelectron spectroscopy (UPS), respectively, using a Thermo Fisher Scientific Nexsa with a multiprobe.

The field emission phenomena occur on the surface of the cathode material. Thus, in this study, the spin-coating technique was used to fabricate films of Bi_2S_3 and $\text{FeS-Bi}_2\text{S}_3$ over an n-type silicon substrate. The fabricated film was used as the cathode material for electron emission at elevated electric field surfaces. The spacing between the anode and cathode was kept at 200 μm in diode configuration. A high vacuum of 1×10^{-7} mbar was maintained. The LabVIEW program was used to record the current and potential measurements and interface them. A Keithley high-voltage power supply with the configuration PS350/5000 V25 W was used to generate high voltage. The voltage applied was divided by the separation between the electrodes to compute the electric field. The field emission current was measured using a Keithley 2000 electrometer. The field emission studies were repeated three times to ascertain the consistency of the results. An interval of 50 V and 10 s was used to record all the values.

3. Results and discussion

In the present work, Bi_2S_3 and $\text{FeS-Bi}_2\text{S}_3$ were synthesized *via* a template-free hydrothermal method.

The XRD diffractogram of the as-synthesized Bi_2S_3 , as shown in Fig. 1, reflects its crystalline nature and is consistent with its orthorhombic phase with the $Pnma$ (62) space group. No other impurity crystal phases were observed. Fig. 2a shows the TEM micrograph of Bi_2S_3 , which reveals the formation of ultrafine rods with a width of ~ 22 nm and length of ~ 300 nm. The high-resolution TEM image in Fig. 2b clearly indicates the single crystalline nature of the Bi_2S_3 nanorods. The adjacent lattice fringes in Fig. 2b show the interplanar spacing of 0.311 nm, which corresponds to the (112) plane of Bi_2S_3 . The EDAX spectra show the presence of Bi and S together with Cu due to the carbon-coated copper grid.

Given that Fe was introduced during the process for the synthesis of Bi_2S_3 , FeS (mackinawite) was formed together with Bi_2S_3 , leading to its decoration on Bi_2S_3 , forming a hetero-

structure. Fig. 3 shows the XRD pattern of the as-formed FeS- Bi_2S_3 heterostructure, which majorly matches Bi_2S_3 , together with overlapped planes of FeS (tetragonal, $P4/nmm$ (129)). The TEM micrograph in Fig. 4a shows that FeS- Bi_2S_3 retained its morphology with the nanorods possessing a length of about 350 nm and width of 30 nm. The HR-TEM image in Fig. 4b shows the close contact of the formed phases with an interpla-

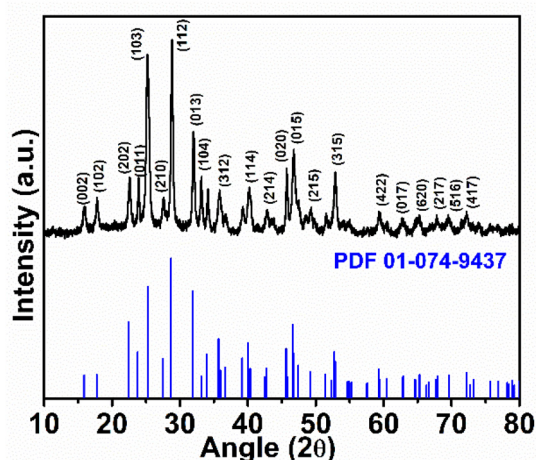


Fig. 1 PXRD pattern of Bi_2S_3 nanorods.

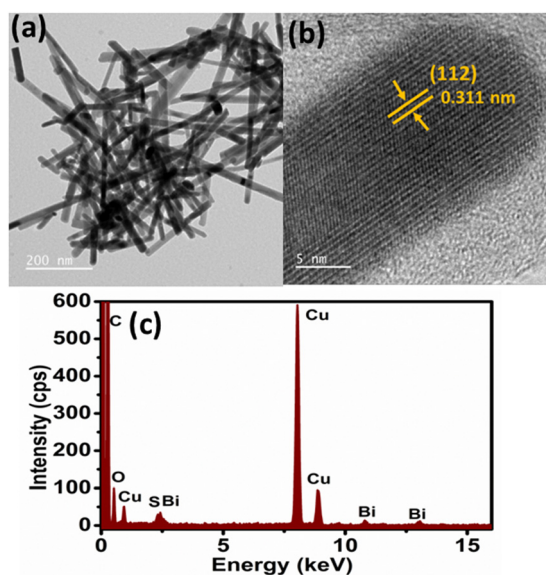


Fig. 2 (a) TEM micrograph, (b) HR-TEM image and (c) electron dispersive spectroscopy (EDS) spectrum of Bi_2S_3 nanorods.

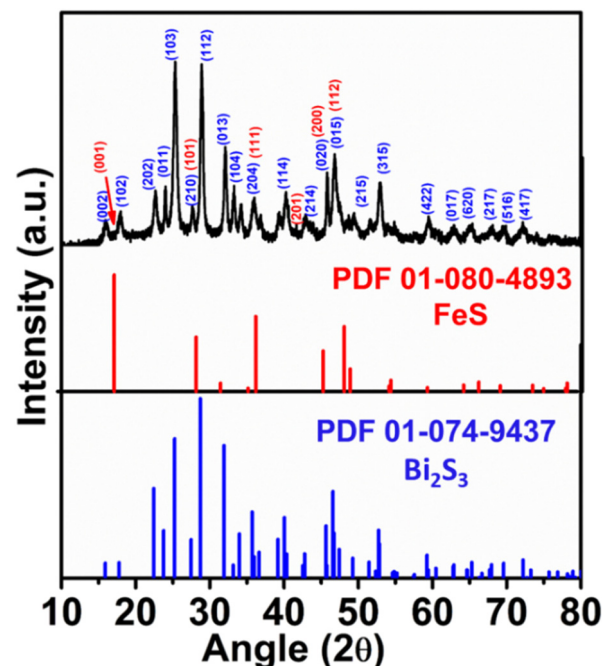


Fig. 3 PXRD pattern of FeS- Bi_2S_3 nanorods.

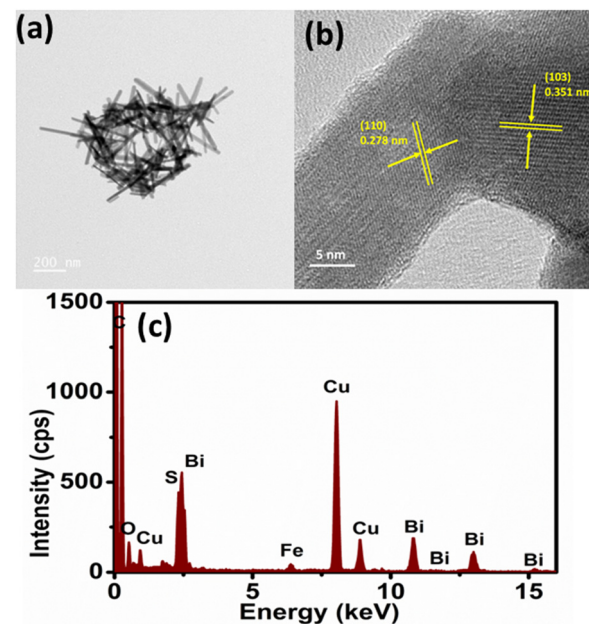


Fig. 4 (a) TEM micrograph, (b) HR-TEM image and (c) electron dispersive spectroscopy (EDS) spectrum of FeS- Bi_2S_3 nanorods.

nar distance of 0.351 nm, which corresponds to the (103) plane of Bi_2S_3 , and an interplanar spacing of 0.278 nm, corresponding to the (110) plane of FeS. The EDAX spectrum of the FeS- Bi_2S_3 heterostructure in Fig. 4c shows the presence of Bi,

Fe and S. The Cu peak originated from the carbon-coated Cu grid mesh. The atomic % (at%) of Bi, S and Fe in Bi_2S_3 and FeS- Bi_2S_3 is presented in Table S1.† The TEM-EDAX mapping in Fig. 5 shows the uniform distribution of Bi, Fe and S in the cluster of the formed nanorods of the heterostructure.

The vibrational peaks in the Raman spectra of Bi_2S_3 appear at 116, 250, 415 and 968 cm^{-1} and FeS- Bi_2S_3 shows peaks at similar values together with one additional peak at 294 cm^{-1} (Fig. S1†). The Raman vibrational peak at 115 cm^{-1} can be assigned to the B_{3u} phonon mode, which is inherently IR active but transforms to the Raman-active mode due to some defects originating from the lattice displacements in Bi_2S_3 . The Raman-active A_g transverse in-plane vibration produced the peak at 250 cm^{-1} . The other peak at 415 cm^{-1} matches well with the value reported in the literature by Sharma *et al.*²⁷ The absorption peak appearing at 968 cm^{-1} is attributed to the surface phonons arising due to the high surface to volume ratio. In the spectrum of FeS- Bi_2S_3 , the additional peak at around 300 cm^{-1} is the characteristic of the symmetric stretch in the FeS bonds in mackinawite.²⁸

To gain insight into the surface composition and oxidation state of Bi_2S_3 and FeS- Bi_2S_3 , they were examined by XPS, as shown in Fig. S2† and Fig. 6, respectively. The survey spectrum of Bi_2S_3 in Fig. S2† shows the presence of Bi and S. The narrow scan spectrum for Bi in Fig. S2(b and c)† shows two peaks centred at 163.28 and 158 eV, corresponding to Bi 4f_{5/2} and Bi 4f_{7/2}, respectively. The spin-orbit coupling doublet of S 2p overlaps with the Bi 4f_{5/2} region in the narrow scan spectrum.

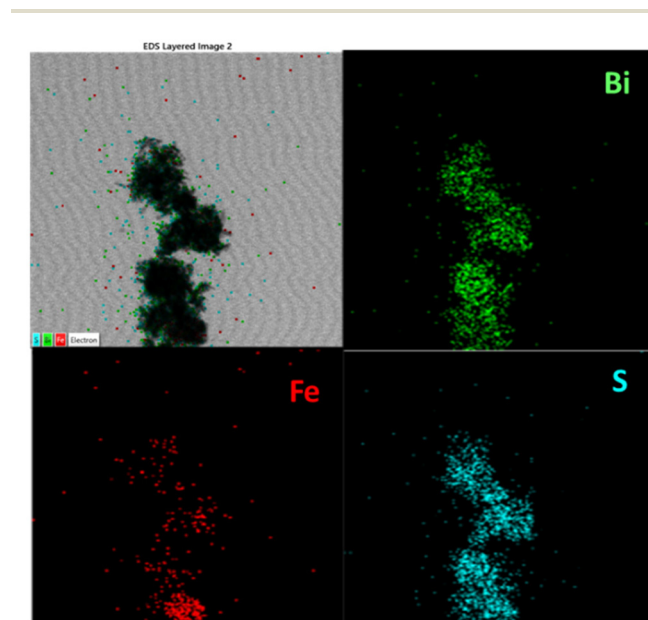


Fig. 5 TEM overlay image and elemental mapping of S, Bi and Fe in FeS- Bi_2S_3 .

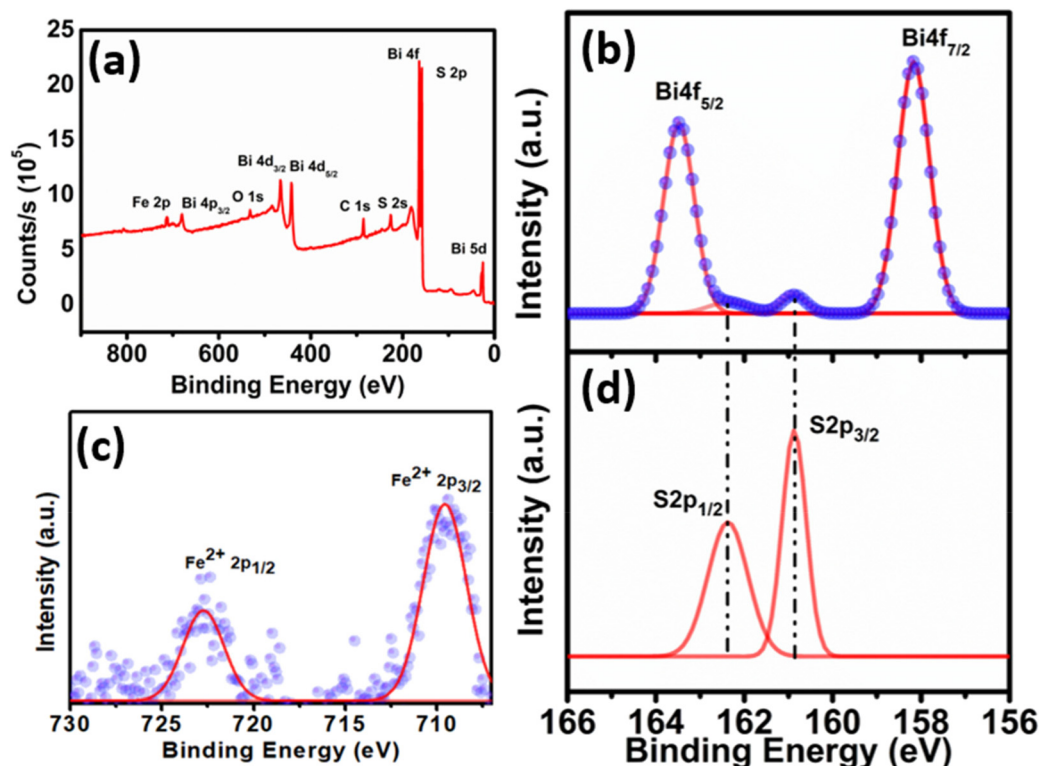


Fig. 6 (a) XPS survey spectrum of FeS- Bi_2S_3 and high-resolution spectra of (b) Bi 4f, (c) Fe 2p and (d) S 2p.

The magnified XPS spectra for the S 2p core levels are shown just below the Bi 4f region in Fig. S2(c)† to effectively distinguish between them. The survey spectrum of FeS-Bi₂S₃ shows signals for Bi, S and Fe (Fig. 6(a)). The high-resolution XPS spectrum of Bi in Fig. 6(b) shows two dominant peaks at 158.18 and 163.48 eV, which correspond to the Bi 4f_{7/2} and Bi 4f_{5/2} spin states in FeS-Bi₂S₃.²⁹ The Fe in FeS-Bi₂S₃ shows peaks at 710.1 and 723 eV, which refer to the spin states of the Fe 2p_{3/2} and Fe 2p_{1/2} core levels, respectively (Fig. 6(c)).³⁰ Both Fe peaks in Fig. 6(c) correspond to the Fe²⁺ oxidation state, which indicates that the Fe in the FeS-Bi₂S₃ lattice is present in the form of FeS. No peaks of Fe in the +3 oxidation state were observed, which rules out the formation of other sulphide species such as Fe₇S₈ and Fe₉S₁₀. Two unsymmetric peaks appear for the S 2p core level region in FeS-Bi₂S₃. The signal for S 2p at 162.3 eV corresponds to S 2p_{3/2} and the peak at 160.8 eV refers to S 2p_{1/2}.

3.1. Field emission studies

Field emission is the quantum mechanical tunnelling phenomena whereby electrons traverse from the cathode, serving as the emitting material, across a vacuum barrier to the anode, propelled by a substantial electric field ranging from 10⁶ to 10⁷ V cm⁻¹ generated by conducting or semiconductor materials. The distance between the cathode and anode is kept fixed at 200 μm. An increase in the aspect ratio and enhanced cathode sharpness, regardless of the material, lead to higher field emission currents. Nanostructures are believed to possess significant application potential in various areas, such as power tubes of microwaves, displays of flat panels, vacuum electronics and various other electron sources. Carbon nanotubes (CNTs) and other nanostructured materials share many advantageous properties and hold great promise for use in field emission (FE) applications. Nanostructured materials exhibit an extraordinarily high thickness to lateral size ratio, known as the aspect ratio. These nanomaterials have protruding and sharp active edges and immense defect sites, which can make electron tunnelling more likely, similar to that seen in carbon nanotubes.

The variation in the emission current density of nanostructured semiconducting materials with a change in electric field is given by the modified Fowler–Nordheim (F–N) equation, as follows:

$$I = Aat_F^{-2}\Phi^{-1}(\beta E)^2 \exp\left\{\frac{-b\nu_F\Phi^{3/2}}{\beta E}\right\} \quad (1)$$

where the first Fowler–Nordheim constant is represented by ‘*a*’ and the second Fowler–Nordheim constant is represented by ‘*b*’, Φ is the work function of the cathode, *A* is the effective area of emission, ν_F and t_F are the values of the special elliptical functions ν and t , respectively, and β is the field enhancement factor. *E* is the externally applied electric field. To determine the local current density *J* at a certain location on the emitting surface, the Fowler–Nordheim theory is employed.

Thus, the field enhancement factor (β_{FE}) is defined as the ratio between the applied and local electric fields, which are

distinct at the emission sites. The combined impact of the increase in local electric field is given by the slope (*m*) of the FN plot and work function (Φ) of the emitting material by the following equation:

$$\beta_{FE} = \frac{(-6.8 \times 10^3)\Phi^{3/2}}{m} \quad (2)$$

The amplification of the field enhancement effect, the promotion of electron entry into the vacuum *via* the tunnelling effect, and the improvement of the field emission performance of the emitter are all correlated with an increase in the value of β . Generally, the β values are related to the spatial distribution of the emission centres, vacuum intervals, crystalline structure, and emitter shape (including aspect ratio). In film field emission, each electron emission site may be regarded as a microtip, which requires a geometric field enhancement factor that can be computed based on its dimensions. The FN theory posits that the field enhancement factor signifies the cumulative impact of all the emission microtips. The β value is determined by calculating the slope of the FN plot, specifically the natural logarithm of (J/E^2) versus $1/E$. The morphology, doping, type of defects, and concentration of defects in a material all affect its work function. The work function of a material greatly affects the current density of field emission. The quantum mechanical tunnelling process serves as the basis for determining the field emission current density from the Fermi energy. The work function (Φ) is defined as the difference between the constant vacuum energy level (E_v) and the Fermi level (E_f). The work function is calculated using ultraviolet photoelectron spectroscopy (UPS) as $\Phi = E_{vac} - E_F$, where E_{vac} represents the converged electrostatic potential in the vacuum region and E_F denotes the Fermi energy, defined here as the valence band maximum (VBM). As shown in Fig. 7, the calculated values of the work function for Bi₂S₃ and FeS-Bi₂S₃ are 4.5 and 3.9 eV, respectively. The effect of an electric field on the field emission current density is proportional to its strength; $E = V/d$, where *V* is the applied voltage and *d* is the distance between the anode and the sample. Because of their high aspect ratio and the greatly improved local electric field anticipated at their edges, nanostructures exhibit qualities that are comparable to or even better than that of carbon nanotubes.

The field emission characteristics (Fig. 8a and 9a) demonstrate that the Bi₂S₃ emitter produced an emission current density of 38.3 μA cm⁻² at an applied field of 7.2 V μm⁻¹, whereas the FeS-Bi₂S₃ emitter produced an emission current density of 48 μA cm⁻² at the field strength of 7.4 V μm⁻¹. The nonlinearity observed in the emitters is a result of their semiconducting nature. This can be attributed to several factors, such as screening of the field amongst adjacent emission sites in the nanostructures, changes in their aspect ratio, penetration of field, band bending, and emission of other energy bands such as bands of metastable surfaces and conduction or valence bands. The F–N plot exhibits nonlinearity throughout the applied field range, which signifies that the emitter possesses semiconducting properties. The conduction band is where most

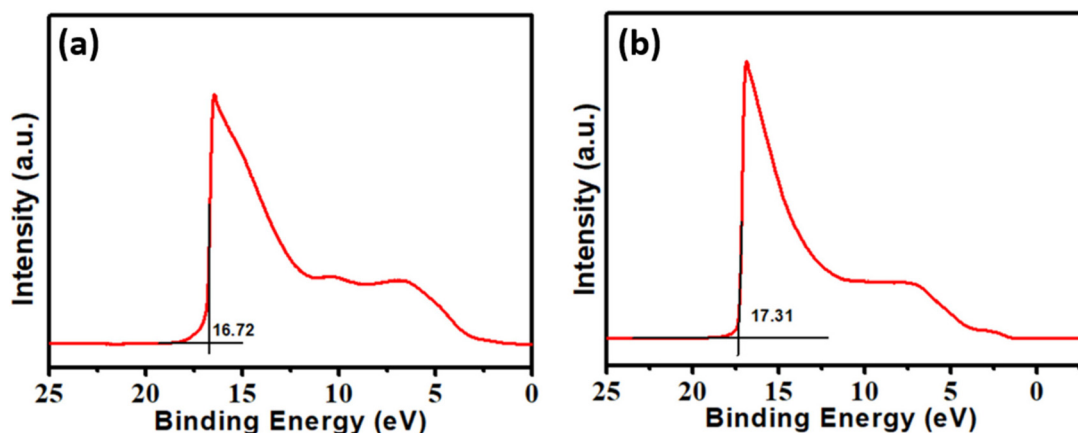


Fig. 7 UPS spectra of (a) Bi_2S_3 and (b) $\text{FeS-Bi}_2\text{S}_3$.

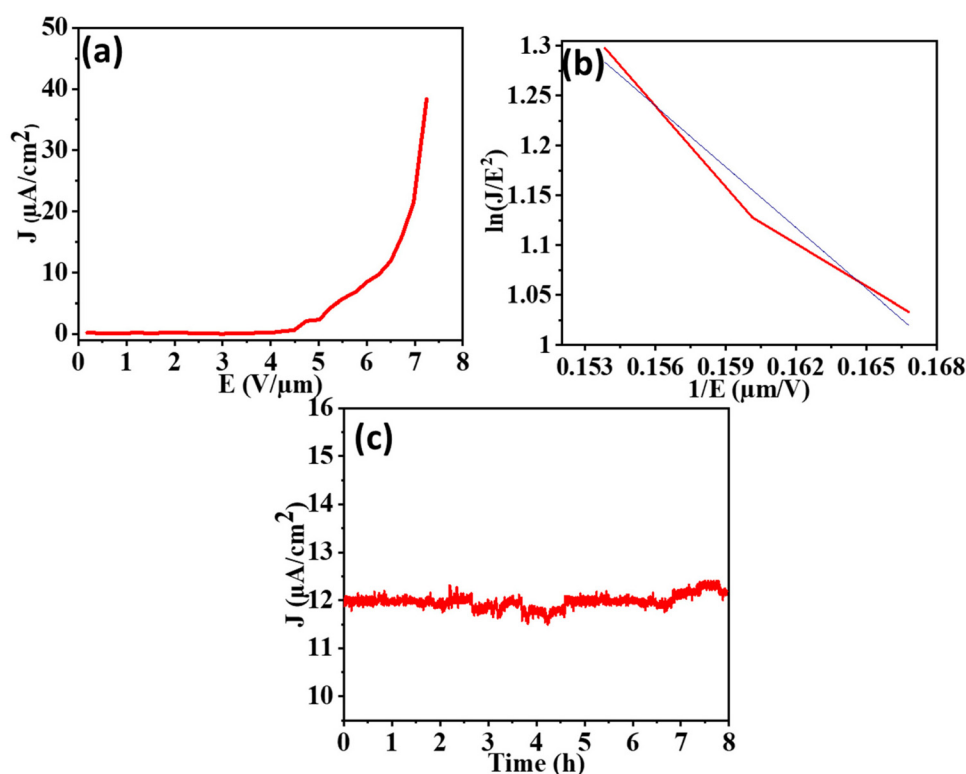


Fig. 8 (a) J - E plot, (b) F - N plot and (c) temporal stability of Bi_2S_3 .

electrons are released when there is a lower applied field. Alternatively, the electrons from the valence band tunnel out as the applied field increases, adding to the emission current.

The cold field emission mechanism is indicated by the negative slope of the straight line that fits the FN plot for both Bi_2S_3 and $\text{FeS-Bi}_2\text{S}_3$. The emitter shape, electrical characteristics, band structure, carrier mobility, crystal structure, surface characteristics, defects and vacancies are some of the variables that affect the density of the emission current. The two primary causes of the disparity in the current density between Bi_2S_3 and $\text{FeS-Bi}_2\text{S}_3$ are their morphology and crystal

structure. The turn-on field refers to the minimum electric field required to provide a current density of $10 \mu\text{A cm}^{-2}$. The measured turn-on field values for Bi_2S_3 and $\text{FeS-Bi}_2\text{S}_3$ are $6.2 \text{ V } \mu\text{m}^{-1}$ and $6.5 \text{ V } \mu\text{m}^{-1}$, respectively. The lower value of the turn-on field meets the requirements for an improved field emitter.

The patterns of field emission current stability for the Bi_2S_3 and $\text{FeS-Bi}_2\text{S}_3$ nanorod field emitters at different set levels are shown in Fig. 8(c) and 9(c), respectively. The measurements were performed every 10 s over an 8 h period with an applied electric field of $12 \text{ V } \mu\text{m}^{-1}$. Both Bi_2S_3 and $\text{FeS-Bi}_2\text{S}_3$ exhibited a consistent emission current density.

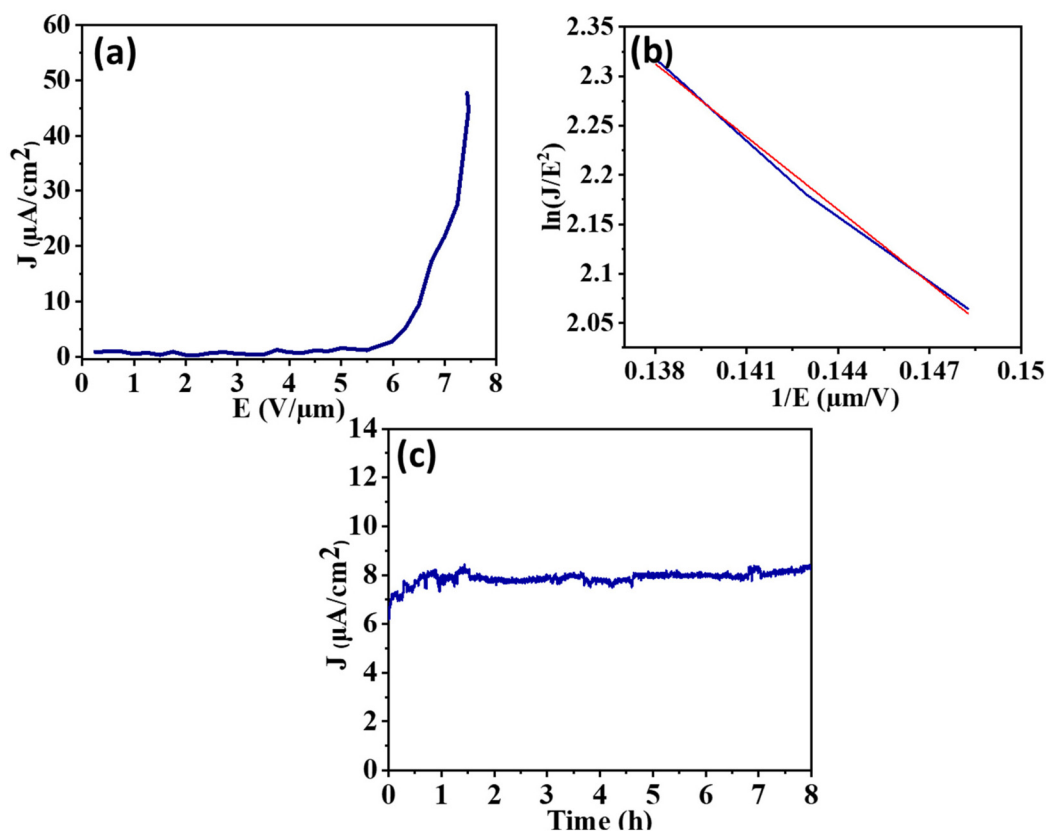


Fig. 9 (a) J - E plot, (b) F - N plot and (c) temporal stability of FeS-Bi₂S₃.

The field enhancement factor values for the Bi₂S₃ and FeS-Bi₂S₃ samples are approximately 3.1×10^3 and 2.2×10^3 , as shown in Fig. 8(b) and 9(b), respectively. Table 1 displays the computed values of the field emission parameters.

Materials with nanostructured surfaces, such as nanowires and nanorods, have higher field enhancement factors because of the localized electric fields at their tips. In the present case, surface modification of Bi₂S₃ by FeS to form the FeS-Bi₂S₃ heterostructure facilitated an enhancement in current density due to the ease of release of surface electrons by lowering the work function of FeS-Bi₂S₃ (3.9 eV). The slight decrease in the field enhancement factor for the FeS-Bi₂S₃ heterostructure is due to its dielectric screening effects and slightly lower aspect ratio (11.6), in which the local electric field is diminished due to polarization effects. The FeS-Bi₂S₃ heterostructure leads to charge redistribution, which will diminish the localized electric field, and thus the field enhancement factor. Thus, both the lowering of the work function and emitter morphology play deciding roles in the enhancement in current density.

The Bi₂S₃ and FeS-Bi₂S₃ nanostructure emitters demonstrated a consistent emission current density of $12 \mu\text{A cm}^{-2}$ and $8 \mu\text{A cm}^{-2}$, respectively, for a duration of 8 h. During the field emission (FE) measurement, the emitter surface is bombarded with ions, causing the gaseous species that are adsorbed onto or trapped between the nanostructures to be released.

The process of cleaning the emitter surface accounts for the enhancement in the emission current. The calculation of the current density fluctuation (c_{flu}) was determined using the following formula:

$$c_{\text{flu}} = \frac{|x - x^-|}{x^-} \times 100 \quad (3)$$

For continuous emission up to 8 h (t), the emission current density (J) recorded at a preset current value of $12 \mu\text{A cm}^{-2}$ and $8 \mu\text{A cm}^{-2}$ for Bi₂S₃ and FeS-Bi₂S₃ exhibited no discernible degradation, with minor current swings of $\pm 3\%$ for the average current values, respectively.

Table 1 Various field emission parameters of the Bi₂S₃ and FeS-Bi₂S₃ samples

Sample	Turn-on field ($\text{V } \mu\text{m}^{-1}$) at $10 \mu\text{A cm}^{-2}$	Slope (eV)	True work function (eV)	Field enhancement factor (β -factor)	J_{max} ($\mu\text{A cm}^{-2}$)
Bi ₂ S ₃	6.2	-20.3	4.5	3.1×10^3	38.3
FeS-Bi ₂ S ₃	6.5	-24.6	3.9	2.2×10^3	47.6

A consistent and steady flow of electric current is necessary for the potential advancement of field emitters in various technological applications. Fig. 8c and 9c display the stability of the field emission (FE) strategy of Bi_2S_3 and $\text{FeS-Bi}_2\text{S}_3$, respectively. The good electrical contact between the silicon substrate and Bi_2S_3 and $\text{FeS-Bi}_2\text{S}_3$ nanorods improves the FE current stability. This feature is remarkable, particularly in the context of an electron source application.

4. Conclusion

The present work demonstrated the simple, facile, template-free hydrothermal synthesis of Bi_2S_3 and $\text{FeS-Bi}_2\text{S}_3$ heterostructure. The TEM analysis showed the formation of nanorods with a length of 350 nm and width of 30 nm. The Raman spectral analysis confirmed the presence of the FeS (mackinawite) phase, together with the signature peak values of Bi_2S_3 in the spectrum of $\text{FeS-Bi}_2\text{S}_3$. The XPS analysis also ruled out the presence of any other oxidation states, ascertaining the presence of FeS in the heterostructure. Further, for the field emission studies, the samples were spin-coated on an Si wafer in the form of a thin film. Both Bi_2S_3 and $\text{FeS-Bi}_2\text{S}_3$ showed almost comparable values for the turn-on field but an enhanced current density value. The field enhancement factor was found to be 2.2×10^3 for $\text{FeS-Bi}_2\text{S}_3$ and 3.1×10^3 for Bi_2S_3 . The introduction of FeS in Bi_2S_3 considerably lowered the work function of Bi_2S_3 from 4.5 eV to 3.9 eV, together with an enhancement in its current density. The introduction of metal sulphides of earth abundant metals such as Fe opens wider prospects for the inclusion of other earth abundant metal ion heterostructures in Bi_2S_3 for studying their field emission properties.

Data availability

Data will be made available upon request.

Conflicts of interest

There are no conflicts of interest to declare.

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